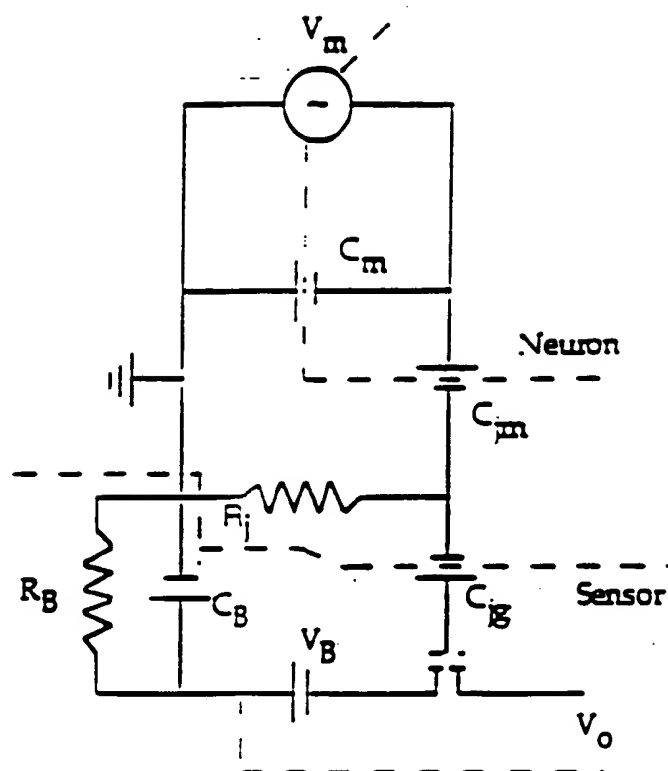


Fig. 1



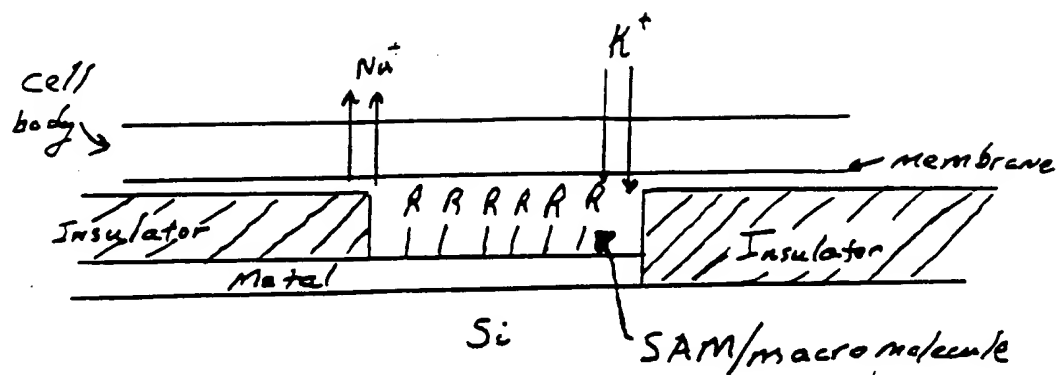


Fig. 2A

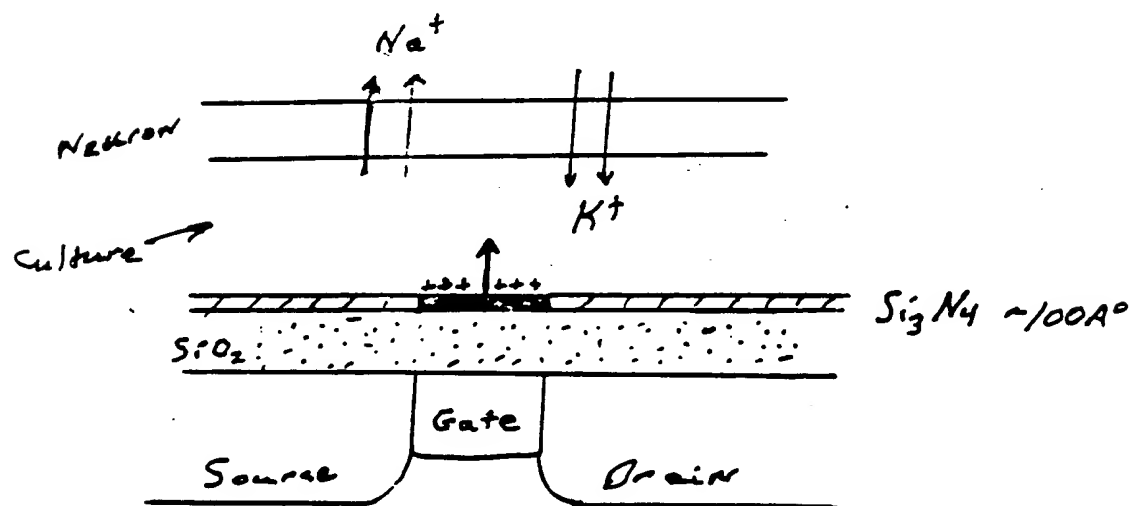
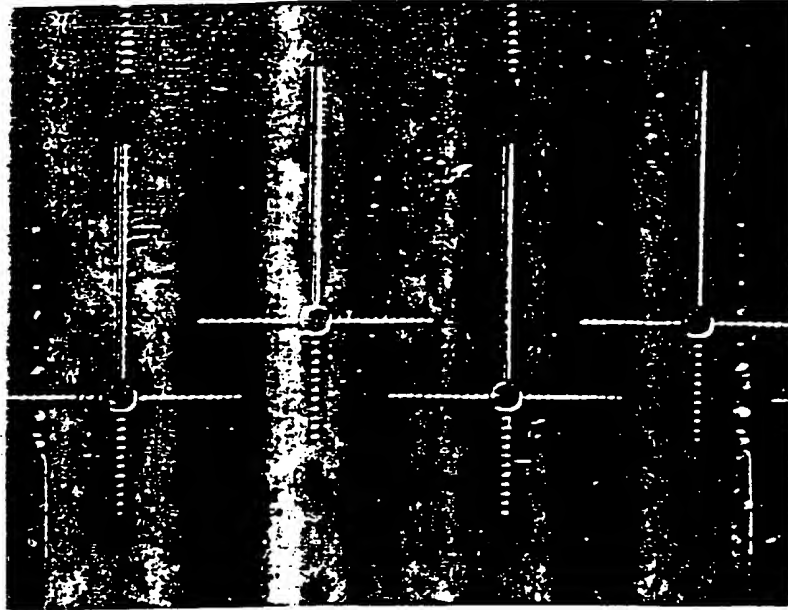


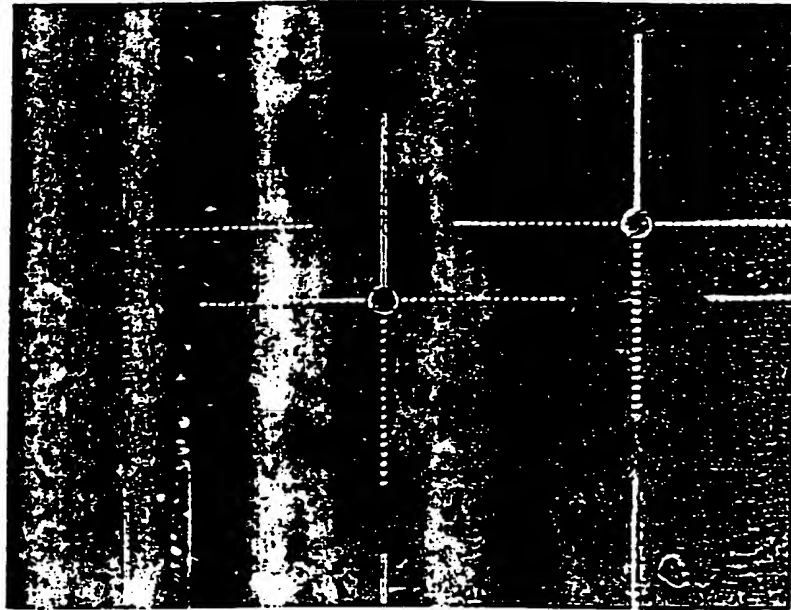
Fig. 2B

FOI 90-8270660



Patt062196: DS100194 Mask, Region 3. Metallized pattern on glass, 4 J/cm<sup>2</sup> dose. 10x objective.

*Figure 3A*

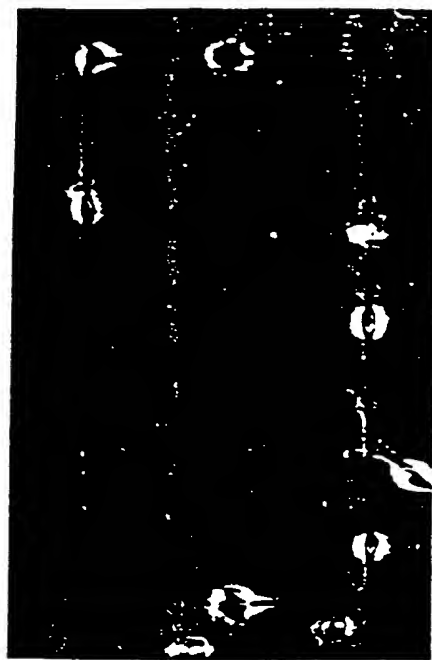
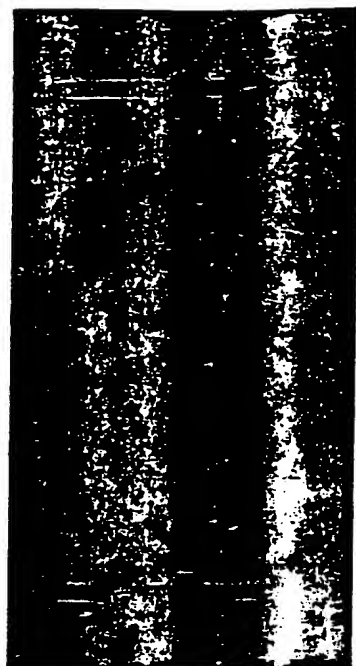


Patt062196: DS100194 Mask, Region 4. Metallized pattern  
on silicon, 4 J/cm<sup>2</sup> dose. 10x objective.

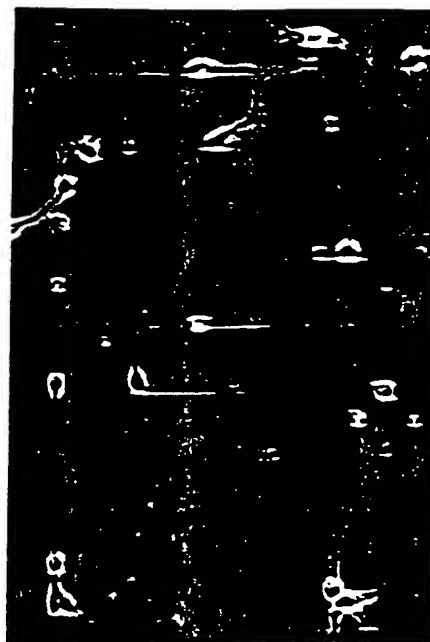
*Figure 3B*

00000196-00000000

(a)



(b)



**Figure 4.** Photographs of the (a) RT12 mask feature and the patterned day 2 *in vitro* hippocampal neurons: (b) RT6 mask feature and the patterned day 2 *in vitro* hippocampal neurons.

000001-000001